

0-3835 U.S. PTO  
10/027882  
12/21/01

PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10027882	FILING DATE 12/21/2001	CLASS 385	SUBCLASS -	GAU 2874	EXAMINER Ahmed
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\*\*APPLICANTS: Novotny Vlad;

\*\*CONTINUING DATA VERIFIED:

THIS APPLN CLAIMS BENEFIT OF 60/206,744 05/24/2000

\*\* FOREIGN APPLICATIONS VERIFIED:

PG-PUB DO NOT PUBLISH ☒

RESCIND ☐

Foreign priority claimed ☐ yes ☐ no  
35 USC 119 conditions met ☐ yes ☐ no

Verified and Acknowledged Examiners's initials

ATTORNEY DOCKET NO

A0-001-2D

TITLE : Deep-well lithography process for forming micro-electro-mechanical structures

U.S. DEPT. OF COMM./PAT. & TM-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED

CLAIMS ALLOWED

Assistant Examiner

Total Claims

Print Claim for  
O.G

ISSUE FEE

Amount Due

Date Paid

DRAWING

Sheets Drwg.

Figs. Drwg.

Print Fig.

Primary Examiner

PREPARED FOR ISSUE

Applicati n Examiner



TERMINAL

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